Negatively refracting chiral metamaterials: a review

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Abstract. Chirality extends the class of negatively refracting metamaterials by endowing a richer palette of electromagnetic properties. Chiral metamaterials can support negative refraction, which must be assessed in light of the closely related phenomenons of negative phase velocity and counterposition. Two categories of chiral metamaterials are being examined these days: (a) homogeneous and homogenizable chiral materials, as exemplified by isotropic chiral materials, Faraday chiral materials, and materials with simultaneous mirror-conjugated and racemic chirality characteristics; and (b) structurally chiral materials, as exemplified by helicoidal bianisotropic materials and ambichiral materials. The planewave response of a half-space occupied by a chiral metamaterial is complex, and important distinctions between negative refraction, negative phase velocity, and counterposition emerge. © 2010 Society of Photo-Optical Instrumentation Engineers. [DOI: 10.1117/6.0000003]

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1 Introduction

Probably the first engineered composite materials were bronze alloys made by smelting copper and tin together more than 5000 years ago. Research on mechanical properties of composite materials has a very rich history, the earliest parts of which are shrouded in the mists of time. Glass too was perhaps created in the Bronze Age, and colored glasses fabricated by mixing some particulate material in silica date back to more than two millenniums ago. Systematic research on optical properties of composite materials began two centuries back, with the publication of the Arago-Biot formula [1]. Since then, theoretical and experimental research continues unabated [2–5].

A composite material must have at least two constituent materials. Each constituent material is chemically inert with respect to the others in its immediate proximity within the composite material. This restriction excludes molecularly pure materials containing two or more types of atoms from being classified as composite materials.

Metamaterials are also composite materials, but with a difference. A metamaterial exhibits response characteristics that either (i) are not observed in or (ii) are enhanced relative to the individual responses of its constituent materials [6]. This characterization of metamaterials captures the notion originally proposed by Walser who envisaged them as being artificial materials fabricated by first downscaling macroscopic material architectures to the submicron and the nanometer length scales and then combining different downscaled architectures into macroscopic materials that would exceed their conventional counterparts in performance [7]. Possessing a cellular morphology, nanoengineered metamaterials may satisfy
complex multifunctional requirements by a judicious juxtaposition of sufficiently small cells of different materials, shapes, and sizes [8].

Our focus in this review is on negatively refracting metamaterials. Millions of research dollars have been spent during the last decade on this topic, following experimental reports of negative refraction in certain metamaterials under microwave illumination [9,10]. Research activity has been greatly fuelled by the possibility of fabricating planar lenses with very high resolving power [11]. Within the past couple of years, metamaterials that exhibit negative refraction at optical frequencies have been developed [12–15], and current efforts are directed toward reducing the considerable dissipative losses associated with optical negative refraction [16,17]. Parenthetically, we note that negative refraction is not exclusive to artificial metamaterials: certain biological structures [18] and naturally occurring minerals [19] also exhibit negative refraction.

The simplest materials that exhibit negative refraction are isotropic dielectric-magnetic materials [20], but the scope for exotic behavior such as negative refraction is considerably increased if chirality is introduced [21–24], especially in combination with anisotropy [25,26] or nonhomogeneity [27,28]. We confine ourselves in this review to chiral and certain related metamaterials—that too of the linear, passive kind.

An object is said to be chiral if it cannot be made to coincide with its mirror image by translations and/or rotations. A remarkable property of chiral materials is that they can discriminate between left-handed and right-handed electromagnetic waves [29]. In order to achieve this discrimination, handedness is necessarily intrinsic to chiral materials. Handedness is manifest in the microstructure of homogeneous and homogenizable chiral materials. For example, an isotropic chiral material comprises a random dispersion of handed molecules or inclusions [29]. An illustration of handed molecules is provided in Fig. 1. In contrast, handedness is manifest at the macroscopic level in structurally chiral materials. For example, the molecules of cholesteric liquid crystals are randomly positioned but macroscopically they exhibit a helicoidal orientational order [30,31], as represented in Fig. 2. Other examples of structurally chiral materials can be fabricated either as stacks of uniaxial laminas [32] or using thin-film technology [33]. Remarkably, artificial examples of both types of chiral materials were produced by Bose more than 111 decades ago [34].

Parenthetically, a third type of “chiral” medium has recently entered scientific literature [35,36]. Such a material is made by depositing spirals (and similar objects) on some flat surface. Spirals, being essentially two-dimensional objects, cannot be chiral, and “planar chirality” [37,38] is an infelicitous term that ought to be replaced by a meaningful term.
In the following sections, we highlight the propensity of chiral metamaterials—of the homogeneous and homogenizable type and of the structurally chiral type—to exhibit negative refraction. Let us remark that, in addition to negative refraction, isotropic [39,40] and bianisotropic [41] chiral materials can support the allied phenomenon of negative reflection under certain conditions.

As regards notational matters: vectors are denoted by boldface with unit vectors being identified by an additional caret. Sans serif boldface indicates either a $3 \times 3$ dyadic or a $4 \times 4$ matrix, and the $3 \times 3$ identity dyadic is written as $I$. The real and imaginary parts of complex-valued quantities are written as $\text{Re}(\cdot)$ and $\text{Im}(\cdot)$; the superscript $^*$ denotes the complex conjugate; and $i = \sqrt{-1}$. The permittivity and permeability of free space (i.e., vacuum) are written as $\epsilon_0$ and $\mu_0$, respectively, and $c_0 = 1/\sqrt{\epsilon_0\mu_0}$. An $\exp(-i\omega t)$ dependence on time is implicit, where $\omega$ is the angular frequency and $t$ is time.

2 Homogeneous and Homogenizable Chiral Materials

2.1 Preliminaries

The characterization of negative refraction by chiral materials is considerably more complicated than of negative refraction by isotropic dielectric-magnetic materials, as more than one refraction wavevector needs to be considered as well as magnetoelectric coupling and possibly directionality [42]. Negative phase velocity (NPV) has been widely adopted as a convenient indicator of negative refraction [43,44]. While NPV and negative refraction go hand-in-hand for uniform planewave propagation in isotropic dielectric-magnetic materials, this is not generally true for nonuniform plane waves, especially in anisotropic materials. The possibility of NPV
propagation in chiral materials was evident some years ago [45], but only nowadays is it being considered carefully [46–54].

Distinctions that can arise between negative refraction and NPV, as well as the closely related phenomenon of counterposition, in chiral metamaterials are highlighted in Sec. 2.5. Here we consider NPV propagation of uniform plane waves in certain well-known chiral materials and metamaterials.

Let us consider electromagnetic field phasors

\[ E(r) = E_0 \exp(i k \hat{k} \cdot r) \]
\[ H(r) = H_0 \exp(i k \hat{k} \cdot r) \]

with complex-valued wavenumber \( k \) and wavevector \( \mathbf{k} = \hat{k}(|\hat{k}| = 1) \), in various types of homogeneous (or homogenizable) chiral materials. These materials are all included in the most general linear category of materials, namely bianisotropic materials, which are characterized by the frequency-domain constitutive relations [55]

\[ \mathbf{D}(r) = \varepsilon \mathbf{E}(r) + \xi \mathbf{H}(r) \]
\[ \mathbf{B}(r) = \zeta \mathbf{E}(r) + \mu \mathbf{H}(r) \]

Combining Eqs. (1) and (2) with the source-free Maxwell curl postulates leads to the algebraic equation

\[ \mathbf{L}(k) \cdot \mathbf{E}(r) = 0 \]

where the 3×3 dyadic

\[ \mathbf{L}(k) = (k \times \mathbf{I} + \omega \xi) \cdot \mu^{-1} \cdot (k \times \mathbf{I} - \omega \zeta) + \omega^2 \varepsilon. \]

Solution of the dispersion relation

\[ \det [\mathbf{L}(k)] = 0 \]

delivers the permissible wavenumbers. Since Eq. (5) represents a quartic polynomial, there are generally four wavenumbers, but the symmetries of the constitutive dyadics \( \varepsilon, \xi, \zeta \) and \( \mu \) may result in the number of independent wavenumbers being less than four.

The phase velocity of the plane wave is classified as negative or positive, depending upon whether the scalar product \( \text{Re} (\mathbf{k} \cdot \mathbf{P}(r)) \) is negative or positive, where

\[ \mathbf{P}(r) = \frac{1}{2} \text{Re} [\mathbf{E}(r) \times \mathbf{H}^*(r)] \]

is the time-averaged Poynting vector. As discussed in Sec. 2.5, the phase velocity can also be orthogonal to the time-averaged Poynting vector; i.e., \( \text{Re} (\mathbf{k} \cdot \mathbf{P}(r)) = 0 \). The ratio of \( k \) to \( k_0 = \omega/c_0 \) may be called a refractive index.

### 2.2 Isotropic Chiral Materials

The simplest chiral materials to consider are the isotropic chiral materials (ICMs). An everyday example of a homogeneous ICM is represented by an aqueous solution of dextrose at optical frequencies [56,57]. As another example, consider a random assembly of right-handed springs, each \( \sim 2 \) mm long and \( \sim 1 \) mm in diameter. While this assembly is nonhomogeneous at optical frequencies, it represents a homogenizable chiral material whose chirality is manifest under
microwave illumination [58–60]. Notice that the latter example represents a chiral metamaterial whereas the former does not. An illustration of an ICM fabricated for microwave applications is provided in Fig. 3.

Mathematically, ICMs are described by their frequency-domain constitutive relations [29]

\[
\begin{align*}
D(r) &= \epsilon E(r) + i \xi H(r), \\
B(r) &= -i \xi E(r) + \mu H(r),
\end{align*}
\]

where \(\xi\) is the chirality parameter. Equation (5) delivers four possible wavenumbers, \(k = k_{ICM}^{(1)}, k_{ICM}^{(2)}, k_{ICM}^{(3)}, \) and \(k_{ICM}^{(4)},\) where

\[
\begin{align*}
k_{ICM}^{(1)} &= -\omega \left(\sqrt{\epsilon \mu + \xi}\right), \\
k_{ICM}^{(2)} &= \omega \left(\sqrt{\epsilon \mu - \xi}\right), \\
k_{ICM}^{(3)} &= -k_{ICM}^{(2)}, \\
k_{ICM}^{(4)} &= -k_{ICM}^{(1)},
\end{align*}
\]
If the inequalities

\[
\text{Re} \left( \sqrt{\varepsilon \mu + \xi} \right) \times \text{Re} \left( \sqrt{\varepsilon^* \mu^*} \right) < 0 \quad \text{for} \quad k = k_{ICM}^{(1),(4)}
\]

\[
\text{Re} \left( \sqrt{\varepsilon \mu - \xi} \right) \times \text{Re} \left( \sqrt{\varepsilon^* \mu^*} \right) < 0 \quad \text{for} \quad k = k_{ICM}^{(2),(3)}
\]

are satisfied, then NPV propagation is supported [24]. For a nondissipative isotropic chiral material (i.e., \( \varepsilon, \xi, \mu \in \mathbb{R} \)) with \( k_{ICM}^{(1),(2),(3),(4)} \in \mathbb{R} \), the NPV conditions [Eqs. (9)] reduce to

\[
\sqrt{\varepsilon \mu} < -\xi \quad \text{for} \quad k = k_{ICM}^{(1),(4)}
\]

\[
\sqrt{\varepsilon \mu} < \xi \quad \text{for} \quad k = k_{ICM}^{(2),(3)}
\]

Thus, we observe that NPV propagation arises only when the magnitude of the chirality parameter \( \xi \) is sufficiently large relative to the magnitude of \( \sqrt{\varepsilon \mu} \) [24,61]. Furthermore, the phase velocity can be positive for the plane waves with wavenumbers \( k_{ICM}^{(1),(4)} \) but negative for the plane waves with wavenumbers \( k_{ICM}^{(2),(3)} \), or vice versa [62]. The boundary between positive and negative phase velocity is characterized by infinite phase velocity [63].

The NPV conditions in Eqs. (9) and (10) highlight a key difference between ICMs and isotropic dielectric-magnetic materials. For the latter (which are described by the constitutive relations in Eq. (7) but with \( \xi = 0 \)), NPV arises when the inequality

\[
\frac{\text{Re} (\varepsilon)}{\text{Im} (\varepsilon)} + \frac{\text{Re} (\mu)}{\text{Im} (\mu)} < 0
\]

is satisfied [44]. For passive isotropic dielectric-magnetic materials, a sufficient set of conditions for NPV is therefore \( \text{Re} (\varepsilon) < 0 \) and \( \text{Re} (\mu) < 0 \). In practice, \( \text{Re} (\varepsilon) < 0 \) may be achieved using metallic materials and \( \text{Re} (\mu) < 0 \) may be achieved using a microstructure based on split-ring resonators (SRRs), but it proves to be tricky to satisfy both of these conditions at the same frequency [20]. The introduction of chirality enables NPV to achieved without it being necessary for Eq. (11) (or \( \text{Re} (\varepsilon) < 0 \) and \( \text{Re} (\mu) < 0 \)) to be met. Furthermore, relatively strong chiral effects may be realized provided that the magnitude of \( \sqrt{\varepsilon \mu} \) is close to zero. A recent example is represented by the chiral metamaterial developed by Wang et al. [54], which exhibits a negative refractive index in the gigahertz frequency range. As shown in Fig. 4, their metamaterial is constructed from SRRs that are arranged on a cubic Bravais lattice. Theoretical and experimental studies confirm that the real part of the refractive index for one wavenumber is negative-valued, as illustrated in Fig. 5.

The prospects of \( |\sqrt{\varepsilon \mu}| \) being close to zero, and thereby satisfying the conditions for NPV, may be enhanced through exploiting materials with either \( |\varepsilon| \approx 0 \) or \( |\mu| \approx 0 \) [64]. Such “epsilon-near-zero” metamaterials have recently been considered for antenna [65], imaging [66], and tunneling [67] applications, whereas “mu-near-zero” metamaterials have been considered for cloaking applications [68]. The canonical case of “epsilon-near-zero” and “mu-near-zero” for achiral materials is represented by nihility [69], wherein \( \varepsilon = \mu = 0 \). By restricting the notion of nihility to a particular frequency regime, and incorporating a nonzero chirality parameter \( \xi \), the notion of chiral nihility emerges [21].

2.3 Faraday Chiral Materials
Suppose we have a random mixture of (i) an isotropic chiral material [29], as described by the frequency-domain constitutive relations in Eqs. (7), and (ii) either a magnetically biased
Fig. 4 The chiral metamaterial of Wang et al. [54]. Four split-ring resonators (a) are locked together to form the unit cell (b); and these unit cells are then arranged on a cubic lattice (c). (Reprinted with permission from Ref. 54. Copyright 2009 by the American Institute of Physics.)

Fig. 5 Theoretical and experimental values of refractive indexes for the chiral metamaterial of Wang et al. [54] at gigahertz frequencies. Here, $\kappa = c_0 \xi$ and $n = c_0 \sqrt{\epsilon \mu}$, with $n_{\pm} = n \pm \kappa$ being the refractive indexes for left- and right-handed waves. According to both theory and experiment, the real part of the index $n_{+}$ is negative at 7.7 GHz. (Reprinted with permission from Ref. 54. Copyright 2009 by the American Institute of Physics.)

plasma [70], as described by the frequency-domain constitutive relations

$$\begin{align*}
\mathbf{D}(r) &= \epsilon_{gyro} \mathbf{E}(r) \\
\mathbf{B}(r) &= \mu_0 \mathbf{H}(r)
\end{align*}$$

or a magnetically-biased ferrite [71], as described by the frequency-domain constitutive relations

$$\begin{align*}
\mathbf{D}(r) &= \epsilon_0 \mathbf{E}(r) \\
\mathbf{B}(r) &= \mu_{gyro} \mathbf{H}(r)
\end{align*}$$
wherein the $3 \times 3$ constitutive dyadics have the gyrotropic form

$$\tau_{\text{gyro}} = \tau I - i \tau \hat{u} \times l + (\tau - \tau) \hat{u} \hat{u}^T, \quad (\tau = \epsilon, \mu).$$

(14)

The unit vector $\hat{u}$ identifies the direction of the biasing magnetic field. The mixture may be regarded as effectively homogeneous provided that wavelengths are much longer than the non-homogeneities of the mixture. The resulting homogenized composite material (HCM)—which is known as a Faraday chiral material—combines natural optical activity, as exhibited by the isotropic chiral constituent material, with Faraday rotation, as exhibited by the gyrotropic constituent material [72].

Provided that the constituent materials are envisioned as electrically small spherical particles, the Faraday chiral material is described by the frequency-domain constitutive relations [73]

$$\begin{align*}
D(r) &= \epsilon^{HCM} \cdot E(r) + i \xi^{HCM} \cdot H(r) \\
B(r) &= -i \xi^{HCM} \cdot E(r) + \mu^{HCM} \cdot H(r)
\end{align*}$$

(15)

where the three $3 \times 3$ constitutive dyadics have the common form

$$\tau^{HCM} = \tau^{HCM} I - i \tau^{HCM} \hat{u} \times l + (\tau^{HCM} - \tau^{HCM}) \hat{u} \hat{u}^T, \quad (\tau = \epsilon, \xi, \mu).$$

(16)

More general Faraday chiral materials can arise through the homogenization of composite materials comprising nonspherical particles [74,75].

The constitutive properties of such HCMs can be estimated using a homogenization formalism. While many different formalisms have been developed [3], the strong-property-fluctuation theory [76,77] provides the basis for a particularly sophisticated homogenization formalism that has been developed for isotropic [78] and anisotropic [75] chiral HCMs. As well as the requirement that the constituent particles of a composite material be electrically small [79,80], the implementation of homogenization formalisms requires that the particles are numerous and distributed statistically uniformly throughout the composite material. Therefore, claims of negative refraction in a chiral metamaterial based on the homogenization of a composite material containing a single chiral inclusion must be regarded warily [81]. In a similar vein, the notion of homogenization precludes the possibility of the constituent materials containing resonant inclusions. Accordingly, claims of a negatively refracting chiral metamaterial arising from the homogenization of resonant inclusions must be viewed with caution too [82]. At best, one can obtain the constitutive parameters of an equivalent homogeneous medium that can replicate the experimental and/or numerical results obtained for a specific source-scatterer-detector configuration [83], but there is no guarantee that those constitutive parameters would be acceptable if the location of the source, the location of the detector, and/or the shape and size of the scatterer were to change without alteration of the composite material that the scatterer is made of.

Planewave propagation in Faraday chiral materials is rather more complicated than it is for isotropic chiral materials, because the effects of directionality come into play. For definiteness, let us choose the unit vector $\hat{k} = \hat{x} \sin \theta + \hat{z} \cos \theta$.

(17)

Equation (5) then has the form [25]

$$a_4 \left( \frac{k}{\omega} \right)^4 + a_3 \left( \frac{k}{\omega} \right)^3 + a_2 \left( \frac{k}{\omega} \right)^2 + a_1 \left( \frac{k}{\omega} \right) + a_0 = 0,$$

(18)

with coefficients

$$a_4 = (\epsilon \sin^2 \theta + \epsilon \cos^2 \theta)(\mu \sin^2 \theta + \mu \cos^2 \theta) - (\xi \sin^2 \theta + \xi \cos^2 \theta)^2.$$  

(19)
Hence, four independent wavenumbers \( k = k_{FCM}^{(1)}, k_{FCM}^{(2)}, k_{FCM}^{(3)}, \) and \( k_{FCM}^{(4)} \) may be extracted as the roots of Eq. (18). Propagation with NPV is supported provided that the real-valued scalar \( W_{FCM} < 0 \), where

\[
W_{FCM} = \text{Re}(k)\text{Re} \left[ \frac{1}{\mu^2_\omega} (\bar{k}^* \sin \theta - i \xi^* \beta^*) \sin \theta \right. \\
+ \left. \frac{1}{(\mu^*)^2 - (\mu_\omega^*)^2} (\bar{k}^* \{ \mu^* (|\alpha|^2 + 1) + i \mu_\omega^* (\alpha - \alpha^*) \} \cos^2 \theta \\
+ \mu^* |\beta|^2 \sin^2 \theta - [\mu^* (\alpha^* \beta + \alpha \beta^*) + i \mu_\omega^* (\beta - \beta^*)] \sin \theta \cos \theta \\
+ (\mu^* \xi^* - \mu_\omega^* \xi^*) [(|\alpha|^2 + 1) \cos \theta - \alpha^* \beta \sin \theta] \\
- i (\mu^* \xi^* - \mu_\omega^* \xi^*) [(\alpha - \alpha^*) \cos \theta - \beta \sin \theta] \right] \tag{24}
\]

and \( \alpha \) and \( \beta \) are defined in terms of entries of \( \mathbf{L}(k) \) per

\[
\alpha = \begin{bmatrix}
[L]_{12} [L]_{13} + [L]_{11} [L]_{23} \\
[L]_{13} [L]_{13} - [L]_{11} [L]_{33}
\end{bmatrix}
\]

\[
\beta = \begin{bmatrix}
[L]_{12} [L]_{23} - [L]_{13} [L]_{22} \\
[L]_{13} [L]_{23} + [L]_{12} [L]_{33}
\end{bmatrix}.
\tag{25}
\]

Matters simplify considerably when propagation is parallel to the \( z \) axis (i.e., \( \theta = 0 \)). The four independent wavenumbers then reduce to

\[
k_{FCM}^{(1)} = \omega \left( \sqrt{\epsilon + \epsilon_\omega \sqrt{\mu + \mu_\omega} - \xi - \xi_\omega} \right) \\
k_{FCM}^{(2)} = \omega \left( -\sqrt{\epsilon + \epsilon_\omega \sqrt{\mu + \mu_\omega} - \xi - \xi_\omega} \right) \\
k_{FCM}^{(3)} = \omega \left( \sqrt{\epsilon - \epsilon_\omega \sqrt{\mu + \mu_\omega} + \xi - \xi_\omega} \right) \\
k_{FCM}^{(4)} = \omega \left( -\sqrt{\epsilon - \epsilon_\omega \sqrt{\mu + \mu_\omega} + \xi - \xi_\omega} \right) \tag{26}
\]

and the NPV parameter \( W_{FCM} \) for each wavenumber becomes

\[
W_{FCM} = 2 \text{Re} \left[ \sqrt{\epsilon + \epsilon_\omega \sqrt{\mu + \mu_\omega} - \xi - \xi_\omega} \right] \text{Re} \left\{ \frac{\sqrt{\epsilon^* + \epsilon_\omega^*}}{\sqrt{\mu^* + \mu_\omega^*}} \right\} \text{ for } k = k_{FCM}^{(1)} \tag{27}
\]
Numerical studies on the homogenization of an isotropic chiral material and a magnetically biased ferrite have revealed that the resulting Faraday chiral material can support NPV propagation provided that the gyrotropic constitutive parameter of the ferrite constituent material is sufficiently large in magnitude relative to the corresponding magnitudes of nongyrotropic permeability parameters [25]. In particular, Faraday chiral materials can support NPV propagation when their constituent materials do not.

A chiral metamaterial with constitutive relations very similar to those of the Faraday chiral material (15) has been developed recently by Zhang et al. [84]. As represented in Fig. 6, their metamaterial comprises metallic chiral resonators in which the loop of the resonator is tilted with respect to a reference plane. This metamaterial exhibits a negative-real refractive index for one wavenumber at frequencies between 1.06 and 1.27 THz, as shown in Fig. 7, despite the magnetic permeability having a positive real part over this frequency range.
Fig. 7 Experimental values of refractive indexes ($n_L$ for left-handed waves and $n_R$ for right-handed waves) for the chiral metamaterial of Zhang et al. [84], plotted against frequency (in terahertz). Also plotted are the dielectric, magnetic, and magnetoelectric constitutive parameters $\epsilon$, $\mu$, and $\xi$ respectively. Real parts are in black and imaginary parts are in gray. The real part of the index $n_L$ is negative between 1.06 and 1.27 THz. (Reprinted with permission from Ref. 84. Copyright 2009 by the American Physical Society.)

2.4 Materials with Simultaneous Mirror-Conjugated and Racemic Chirality Characteristics

Let us next consider an isotropic chiral material described by the constitutive relations in Eq. (7). The mirror conjugate material is also an isotropic chiral material, described by the constitutive relations in Eq. (7) but with the chirality parameter $\xi$ replaced by $-\xi$. When an isotropic chiral material and its mirror conjugate are mixed together in a random fashion, in equal proportions (and provided that no chemical reactions or molecular conformational changes occur), the resulting racemic mixture is an isotropic dielectric-magnetic material; i.e., it is achiral. However, an isotropic chiral material and its mirror conjugate can be mixed together in equal proportions and yet retain chirality, thereby producing a material with simultaneous mirror-conjugated and racemic chirality (SMCRC) characteristics. This can be achieved by fixing the orientations of the chiral elements that make up the constituents of the mixture. For example, an artificial SMCRC
material may be conceptualized as a mixture of equal proportions of left-handed springs aligned along the $x$ axis and right-handed springs along the $y$ axis; and left- as well as right-handed springs in equal proportions aligned along the $z$ axis [85]; all springs are electrically small. Also, certain naturally occurring minerals exhibit SMCRC below their Néel temperatures [86,87].

The $3 \times 3$ constitutive dyadics of an SMCRC material may be expressed as

$$
\begin{align*}
\epsilon &= \epsilon_1(\hat{x}\hat{x} + \hat{y}\hat{y}) + \epsilon_3\hat{z}\hat{z} \\
\xi &= \xi(\hat{x}\hat{x} - \hat{y}\hat{y}) \\
\zeta &= -\xi,
\end{align*}
$$

(31)

Equation (5) yields the four wavenumbers $k = k_{SCMC}(1), k_{SCMC}(2), k_{SCMC}(3)$, and $k_{SCMC}(4)$.

However, since SMCRC materials are Lorentz-reciprocal [88], there are only two independent wavenumbers, at most. For propagation in an arbitrary direction given by

$$
\hat{k} = \hat{x} \sin \theta \cos \phi + \hat{y} \sin \theta \sin \phi + \hat{z} \cos \theta, 
$$

(32)

the wavenumbers are [85]

$$
\begin{align*}
k_{SCMC}(1) &= \omega \sqrt{b_3 (b_1 - b_2)} \\
k_{SCMC}(2) &= -k_{SCMC}(1) \\
k_{SCMC}(3) &= \omega \sqrt{b_3 (b_1 + b_2)} \\
k_{SCMC}(4) &= -k_{SCMC}(3)
\end{align*}
$$

(33)

wherein the scalars

$$
\begin{align*}
b_1 &= 2\epsilon_3 \mu_3 \cos^2 \theta + (\epsilon_1 \mu_1 + \epsilon_3 \mu_3) \sin^2 \theta \\
b_2 &= \sin^2 \theta \sqrt{(\epsilon_1 \mu_1 - \epsilon_3 \mu_3) - 4\epsilon_3 \mu_3 \xi^2 \cos 2\phi} \\
b_3 &= \frac{1}{2} (\epsilon_1 + \xi^2) [(\epsilon_1 \sin^2 \theta + \epsilon_3 \cos^2 \theta)(\mu_1 \sin^2 \theta + \mu_3 \cos^2 \theta) + \xi^2 \sin^4 \theta \cos^2 2\phi]^{-1}
\end{align*}
$$

(34)

are introduced. Propagation of plane waves with NPV is supported provided that the real-valued scalar $W_{SMC} < 0$, where [26]

$$
W_{SMC} = \text{Re}(k) \left( \frac{1}{\omega} \left[ (|\alpha|^2 + |\beta|^2) \cos^2 \theta + \sin^2 \theta \\
- (|\alpha + \alpha^*| \cos \phi + (\beta + \beta^*) \sin \phi) \sin \theta \cos \theta \right] \\
+ \text{Re} \left( \frac{k^*}{\mu_1} \right) + \frac{1}{\omega} (\alpha \sin \phi - \beta \cos \phi)(\alpha^* \sin \phi - \beta^* \cos \phi) \sin^2 \theta \text{Re} \left( \frac{k^*}{\mu_3} \right) \\
+ \sin \theta \text{Re} \left( \frac{\alpha^* \sin \phi + \beta^* \cos \phi}{\mu_1} \right) - (\alpha^* \alpha + \beta^* \beta) \cos \theta \text{Re} \left( \frac{\xi^*}{\mu_1} \right) \right),
$$

(35)

and the scalars $\alpha$ and $\beta$ are defined as in Eqs. (25).

For planewave propagation along the racemic axis (i.e., $\hat{k} = \hat{z}$), only one independent wavenumber, namely

$$
k_{SCMC}(1) = -k_{SCMC}(2) = k_{SCMC}(3) = -k_{SCMC}(4) = \omega \sqrt{\epsilon_1 \mu_1 + \xi^2},
$$

(36)
emerges from Eq. (5). The corresponding NPV parameter $W_{\text{SMRC}}$ simplifies as

$$ W_{\text{SMRC}} = \left(\left|\frac{\alpha}{\beta}\right|^2 + 1\right) \text{Re} \left[ \frac{\left(\sqrt{\epsilon_1 \mu_1 + \xi^2}\right)^*}{\mu_1^*} \right] $$

$$ - 2\text{Re} \left(\frac{\alpha}{\beta}\right) \text{Re} \left(\frac{\xi^*}{\mu_1^*}\right) \text{Re} \left(\sqrt{\epsilon_1 \mu_1 + \xi^2}\right) \quad \text{for} \quad k = k_{\text{SMRC}}^{(1)} \quad (37) $$

$$ W_{\text{SMRC}} = \left(\left|\frac{\alpha}{\beta}\right|^2 + 1\right) \text{Re} \left[ \frac{\left(\sqrt{\epsilon_1 \mu_1 + \xi^2}\right)^*}{\mu_1^*} \right] $$

$$ + 2\text{Re} \left(\frac{\alpha}{\beta}\right) \text{Re} \left(\frac{\xi^*}{\mu_1^*}\right) \text{Re} \left(\sqrt{\epsilon_1 \mu_1 + \xi^2}\right) \quad \text{for} \quad k = k_{\text{SMRC}}^{(2)} \quad (38) $$

Numerical studies indicate that NPV arises as long as the magnitude of the magneto-electric constitutive parameter $\xi$ is sufficiently large compared with the magnitudes of dielectric and magnetic constitutive parameters [26]. In addition, the directions of NPV propagation are influenced little by $|\xi|$. Furthermore, the incorporation of dielectric and magnetic constitutive parameters with negative-real parts enhances the propensity for NPV propagation.

2.5 Counterposition, Negative Phase Velocity, and Negative Refraction

While NPV may be a useful indicator of the propensity for negative refraction by certain homogeneous materials, NPV can arise in the absence of negative refraction (and vice versa) in certain anisotropic [89] and bianisotropic [90] materials and metamaterials. Furthermore, from a practical point of view, the direction of energy flow, as provided by the time-averaged Poynting vector, may be more pertinent than the direction of the wavevector. Therefore, in the context of NPV and negative refraction, the phenomenon of counterposition should be considered too. This arises at a planar interface when the refraction wavevector and its associated time-averaged Poynting vector are oriented on opposite sides of the normal to the interface, as has been described for certain crystals [91,92].

In order to explore the relationships between counterposition, NPV and negative refraction, let us focus on the Lorentz-reciprocal [88] bianisotropic material—known as a pseudochiral omega material [93]—described by the constitutive dyadics [94]

$$ \begin{align*}
\epsilon &= \epsilon_x \hat{x}\hat{x} + \epsilon_y \hat{y}\hat{y} + \epsilon_z \hat{z}\hat{z} \\
\xi &= -i\xi \hat{y}\hat{z} \\
\zeta &= i\xi \hat{z}\hat{y} \\
\mu &= \mu_x \hat{x}\hat{x} + \mu_y \hat{y}\hat{y} + \mu_z \hat{z}\hat{z}
\end{align*} \quad \text{(39)} $$

These particular constitutive dyadics are used to describe a metamaterial assembled from layers of split-ring resonators [98], this being a commonplace configuration for metamaterials [99,100]. As well as NPV, such magnetoelectric metamaterials may support other exotic electromagnetic phenomena, for example, longitudinal polarization [101].

Suppose that a metamaterial described by Eqs. (39) fills the half-space $z > 0$, while the half-space $z < 0$ is vacuous. The wave vectors of the incident, the reflected, and the refracted plane waves lie wholly in the $xz$ plane. The wavevectors for the two refracted plane waves that exist in the half-space $z > 0$ may be expressed as

$$ k^{(j)} = k \hat{x} + k_c \hat{z}, \quad (j = 1, 2). \quad \text{(40)} $$
Mackay and Lakhtakia: Negatively refracting chiral metamaterials

\[ \kappa = k_0 \sin \theta \in [0, k_0), \]  

(41)

with the free-space wavenumber \( k_0 = \omega \sqrt{\varepsilon_0 \mu_0} \). The wavevector components \( k_{zj} \) are delivered from Eq. (5) as follows:

\[
egin{align*}
    k_{z1} &= k_0 \sqrt{\mu_x \left( \varepsilon_y - \frac{k_0^2}{\mu_z k_0^2} \right)} \\
    k_{z2} &= k_0 \sqrt{\varepsilon_z \left( \mu_z \varepsilon_y - \xi^2 \right) - \frac{k_0^2}{\mu_z k_0^2}} 
\end{align*}
\]

(42)

Herein, the square roots must be evaluated such that both refracted plane waves transport energy away from the interface \( z = 0 \) in the half-space \( z > 0 \). Since \( k_{zj} \in \mathbb{C} \) in general, the refracted plane waves may be nonuniform. The time-averaged Poynting vector corresponding to the plane wave labeled as \( j \) is written as \( \mathbf{P}_j \).

Confusingly, the term **negative refraction** has been used to mean different things. The sense of refraction is determined solely by the relative orientations of the real parts of the refraction and incidence wavevectors, in keeping with Snell’s law, which emanates from the principle of conservation of linear momentum. Thus, negative refraction arises whenever the real part of \( k_{z1} \) (or \( k_{z2} \)) is negative. In contrast, negative refraction was also set up \[89\] as the negative “**refraction of the energy flux density**,” but it amounts to a negative-deflection phenomenon that can occur whether refraction is positive or negative and is easily appreciated as such when the incident plane wave is replaced by a beam (of finite width). Similar comments apply to certain later works too \[95–97\].

In order to illustrate the distinctions between counterposition, NPV, and negative refraction, let us investigate a specific example in which the constitutive parameters for the bianisotropic material occupying the half-space \( z > 0 \) are: \( \varepsilon_x = 0.1 + 0.03i, \, \varepsilon_y = 0.14 + 0.02i, \, \varepsilon_z = 0.13 + 0.07i; \, \mu_x = -0.2 + 0.2i, \, \mu_y = -0.22 + 0.03i, \, \mu_z = -0.27 + 0.6i; \) and \( \xi = 0.21 + 0.05i \). This is a dissipative material.

The real part of \( k_{z1}/k_0, \ (j = 1, 2) \), is plotted as a function of \( (\kappa/k_0) \in [0, 1) \) in Fig. 8. Also presented in Fig. 8 are plots of the angle between the real part of \( \mathbf{k}^{(j)}, \ (j = 1, 2) \), and the positive \( z \) axis. We see that the refracted plane wave labeled 1 is positively refracted for \( 0 < (\kappa/k_0) < 0.4 \) but negatively refracted for \( 0.4 < (\kappa/k_0) < 1 \); also, the refracted plane wave labeled 2 is negatively refracted for \( 0 < (\kappa/k_0) < 0.29 \) but positively refracted for \( 0.29 < (\kappa/k_0) < 1 \).
Fig. 9 (a) The $x$ component of the normalized time-averaged Poynting vector and (b) the angle (in degrees) between the time-averaged Poynting vector and the positive $z$ axis, both plotted against $\kappa/k_0$. The solid curves correspond to the plane wave labeled $j = 1$, and the dashed curves to the plane wave labeled $j = 2$. Note that $\hat{z} \cdot \mathbf{P} > 0$ for all $\kappa/k_0 \in [0, 1)$, for both plane waves. See Sec. 2.5 for other details.

Since the imaginary parts of both $k_{z1}$ and $k_{z2}$ are positive, both refracted plane waves attenuate as $z \to \infty$.

In Fig. 9, the normalized $x$ component of the time-averaged Poynting vectors for both refracted plane waves are plotted against $(\kappa/k_0)$. Also plotted is the angle between $\mathbf{P}_j$ and the positive $z$ axis, for both refracted plane waves. The $x$ component of $\mathbf{P}_1$ is negative for all $\kappa/k_0 \in [0, 1)$, but the $x$ component of $\mathbf{P}_2$ is negative only for $\kappa/k_0 \in [0, 0.06)$. That is, $\mathbf{P}_1$ always subtends a negative angle to the positive $z$ axis while the sign of the angle that $\mathbf{P}_2$ subtends depends on $\kappa$. The $z$ components of $\mathbf{P}_j$ for both refracted plane waves are positive for all $\kappa/k_0 \in [0, 1)$, as is required by the choice of square roots in Eq. (42).

When the inequality

$$\text{Re}(k_{zj}) \hat{x} \cdot \mathbf{P}_j < 0$$

is satisfied, counterposition occurs [92]. From Figs. 8 and 9, it may be inferred that counterposition occurs for the refracted plane wave labeled 1 when $0 < (\kappa/k_0) < 0.4$. Hence, the $\kappa$-range for positive refraction is the same as that for counterposition for the plane wave labeled 1. This contrasts with the situation for the plane wave labeled 2 where counterposition arises only for $0.06 < (\kappa/k_0) < 0.29$.

The sign of the phase velocity for the plane wave labeled $j$ is determined the quantity $\text{Re}(k^{(j)} \mathbf{P}_j)$, which is plotted against $(\kappa/k_0) \in [0, 1)$ in Fig. 10. The refracted plane wave labeled 1 has NPV for $0.18 < (\kappa/k_0) < 1$, whereas NPV is exhibited by the refracted plane wave labeled 2 for $0 < (\kappa/k_0) < 0.08$. Notice that the $\kappa$-ranges for NPV and negative refraction do not coincide. Take, for example, $\kappa = 0.2k_0$: (i) The angle between $\text{Re}(k^{(1)})$ and the $+z$ axis is 79 deg and the angle between $\mathbf{P}_1$ and the $+z$ axis is $-15$ deg. Thus, here the plane wave is
Table 1 Values of $\kappa$ for which negative/positive refraction, counterposition, and negative/positive/orthogonal phase velocity occur for the plane wave labeled 1. The right-most column shows the directions in the half-space $z > 0$ of $\text{Re}(k^{(1)})$ (thick dashed arrows) and $\mathbf{P}_1$ (thick solid arrows) for representative values of $\kappa$; also shown are the directions of the wavevectors for the incident and reflected plane waves in the half-space $z < 0$ (thin solid arrows).

<table>
<thead>
<tr>
<th>$(\kappa / k_0)$</th>
<th>Refraction</th>
<th>Counter-position</th>
<th>Phase velocity</th>
<th>$\mathbf{P}_1$, $\text{Re}(k^{(1)})$</th>
</tr>
</thead>
<tbody>
<tr>
<td>(0, 0.18)</td>
<td>+ve</td>
<td>yes</td>
<td>+ve</td>
<td></td>
</tr>
<tr>
<td>(0.18)</td>
<td>+ve</td>
<td>yes</td>
<td>orthogonal</td>
<td></td>
</tr>
<tr>
<td>(0.18, 0.4)</td>
<td>+ve</td>
<td>yes</td>
<td>–ve</td>
<td></td>
</tr>
<tr>
<td>(0.4, 1)</td>
<td>–ve</td>
<td>no</td>
<td>–ve</td>
<td></td>
</tr>
</tbody>
</table>

positively refracted but it has NPV. (ii) The angle between $\text{Re}(k^{(2)})$ and the $+z$ axis is $-87$ deg and the angle between $\mathbf{P}_2$ and the $+z$ axis is $50$ deg. This plane wave is negatively refracted despite having positive phase velocity.

Exceptionally, the phase velocity can be neither positive nor negative. At $\kappa = 0.18k_0$, the phase velocity vector and the time-averaged Poynting vector are orthogonal for the plane wave labeled 1. Orthogonal phase velocity occurs for the plane wave labeled 2 at $\kappa = 0.08k_0$.

The foregoing results are summarized in Tables 1 and 2 for the plane waves labeled 1 and 2, respectively. Included in these tables are illustrations of the directions of $\text{Re}(k^{(j)})$ and $\mathbf{P}_j$ ($j = 1, 2$), for representative values of $\kappa$. This numerical example illustrates the complexity that can arise at the planar boundary of a chiral metamaterial—indeed, the independence of negative refraction and NPV can even arise for isotropic dielectric materials if nonuniform plane waves are taken into consideration [90].
Table 2 As Table 1 but for the plane wave labeled 2.

<table>
<thead>
<tr>
<th>$(\kappa/k_0)\epsilon$</th>
<th>Refraction</th>
<th>Counter-position</th>
<th>Phase velocity</th>
<th>$P_2$, $\text{Re}(k^{(2)})$</th>
</tr>
</thead>
<tbody>
<tr>
<td>(0.06)</td>
<td>−ve</td>
<td>no</td>
<td>−ve</td>
<td></td>
</tr>
<tr>
<td>(0.06, 0.08)</td>
<td>−ve</td>
<td>yes</td>
<td>−ve</td>
<td></td>
</tr>
<tr>
<td>(0.08)</td>
<td>−ve</td>
<td>yes</td>
<td>orthogonal</td>
<td></td>
</tr>
<tr>
<td>(0.08, 0.29)</td>
<td>−ve</td>
<td>yes</td>
<td>+ve</td>
<td></td>
</tr>
<tr>
<td>(0.29, 1)</td>
<td>+ve</td>
<td>no</td>
<td>+ve</td>
<td></td>
</tr>
</tbody>
</table>
3 Structurally Chiral Materials

3.1 Preliminaries

In contrast to the materials considered in Sec. 2, structurally chiral materials owe their chirality to the handedness of their morphology at macroscopic length scales (i.e., at length scales comparable to the wavelength). A very general class of structurally chiral materials is represented by helicoidal bianisotropic materials (HBMs). These include chiral nematic and chiral smectic liquid crystals as well as sculptured thin films. The nonhomogeneity of HBMs—which gives rise to their chirality—is spatially continuous at macroscopic length scales. Another technologically important type of structurally chiral material is represented by ambichiral materials. These are piecewise homogeneous in a certain direction [32]. The propensity of both HBMs and ambichiral materials to support negative refraction is reviewed in the following sections.

3.2 Helicoidal Bianisotropic Materials

The frequency-domain constitutive relations [102]

\[
\begin{align*}
D(r) &= \epsilon_{HBM}(z) \cdot E(r) + \xi_{HBM}(z) \cdot H(r) \\
B(r) &= \zeta_{HBM}(z) \cdot E(r) + \mu_{HBM}(z) \cdot H(r)
\end{align*}
\]  

describe a HBM with the z axis being the helicoidal axis. The four 3×3 nonhomogeneous constitutive dyadics herein have the general form

\[
\beta_{HBM}(z) = \begin{pmatrix}
\beta_{11}(z) & \beta_{12}(z) & \beta_{13}(z) \\
\beta_{21}(z) & \beta_{22}(z) & \beta_{23}(z) \\
\beta_{31}(z) & \beta_{32}(z) & \beta_{33}(z)
\end{pmatrix}, \quad (\beta = \epsilon, \xi, \zeta, \mu).
\]  

(45)

and may be expressed as

\[
\beta_{HBM}(z) = S(z) \cdot \beta_{HBM}(0) \cdot S^{-1}(z), \quad (\beta = \epsilon, \xi, \zeta, \mu).
\]  

(46)

The helicoidal architecture is specified by the rotation dyadic

\[
S(z) = \begin{pmatrix}
cos \left( \frac{\pi z}{\Omega} \right) & -h \sin \left( \frac{\pi z}{\Omega} \right) & 0 \\
h \sin \left( \frac{\pi z}{\Omega} \right) & \cos \left( \frac{\pi z}{\Omega} \right) & 0 \\
0 & 0 & 1
\end{pmatrix},
\]  

(47)

with \( \Omega \) being the half-period. The HBM is structurally right-handed if \( h = 1 \), left-handed if \( h = -1 \), and structurally achiral if \( h = 0 \).

A host of structurally chiral materials are encompassed by the constitutive Eqs. (44). The chirality may be purely dielectric, in which case \( \xi_{HBM} = \zeta_{HBM} = 0 \) and \( \mu_{HBM} = \mu_0 I \). This subcategory includes chiral nematic liquid crystals (wherein \( \epsilon_{HBM} \) has a uniaxial form), chiral smectic liquid crystals (wherein \( \epsilon_{HBM} \) has a biaxial form) [30,31]; and their solid-state counterparts called chiral sculptured thin films [33]. Illustrations of organic and inorganic chiral sculptured thin films, both fabricated by vapor deposition techniques, are provided in Fig. 11.

The chirality may also be purely magnetic, in which case \( \xi_{HBM} = \zeta_{HBM} = 0 \) and \( \epsilon_{HBM} = \epsilon_0 I \). Fully bianisotropic chirality may be achieved through infiltrating a chiral sculptured thin film with an isotropic chiral fluid [104,105].

Most notably, HBMs can discriminate between left- and right-circularly polarized light. Let us consider a plane wave normally incident on a slab of an HBM that has its helicoidal axis
aligned with the direction of slab thickness. Within a certain wavelength regime, the incident light may be almost entirely reflected if the structural handedness of the HBM coincides with the handedness of the incident light. Conversely, if the two handednesses are opposite then the incident light will undergo almost no reflection. This circular Bragg phenomenon underpins many actual and potential technological applications of HBMs [33].

The propagation of plane waves in HBMs has been comprehensively analyzed [102,106]. Combining the constitutive Eqs. (44) with the source-free Maxwell curl postulates yields the system of partial differential equations

\[
\begin{align*}
\nabla \times \mathbf{E}(\mathbf{r}) &= i\omega \left[ \zeta_{HBM}(z) \cdot \mathbf{E}(\mathbf{r}) + \mu_{HBM}(z) \cdot \mathbf{H}(\mathbf{r}) \right], \\
\nabla \times \mathbf{H}(\mathbf{r}) &= -i\omega \left[ \epsilon_{HBM}(z) \cdot \mathbf{E}(\mathbf{r}) + \xi_{HBM}(z) \cdot \mathbf{H}(\mathbf{r}) \right].
\end{align*}
\]

(48)

Upon implementing the Oseen transformation [109]

\[
\begin{align*}
\mathbf{E}'(\mathbf{r}) &= \mathbf{S}^{-1}(z) \cdot \mathbf{E}(\mathbf{r}), \\
\mathbf{H}'(\mathbf{r}) &= \mathbf{S}^{-1}(z) \cdot \mathbf{H}(\mathbf{r}).
\end{align*}
\]

(49)

Fig. 11 Scanning electron microscope images of chiral sculptured thin films made from silicon oxide (top, Courtesy of Mark W. Horn, Pennsylvania State University) and parylene [103] (bottom).
and introducing the planewave representations

\[
E'(r) = E_0'(z) \exp(i \kappa_{HBM} x)
\]

\[
H'(r) = H_0'(z) \exp(i \kappa_{HBM} x)
\]

wherein \( \kappa_{HBM} \) may be interpreted as a wavenumber in the \( xy \) plane. Eqs. (48) generally reduce to the \( 4 \times 4 \) matrix differential equation

\[
\frac{\partial}{\partial z} F_0'(z) = M'(z) \cdot F_0'(z).
\]

Herein, the column 4-vector

\[
F_0'(z) = \begin{bmatrix}
  \hat{x} \cdot E_0'(z) \\
  \hat{y} \cdot E_0'(z) \\
  \hat{x} \cdot H_0'(z) \\
  \hat{y} \cdot H_0'(z)
\end{bmatrix},
\]

and the \( 4 \times 4 \) matrix function \( M'(z) \) may be formally expressed as

\[
M'(z) = A' + \kappa_{HBM} \left[ C_{1,1} \exp\left(\frac{i \pi z}{\Omega}\right) + C_{1,-1} \exp\left(-\frac{i \pi z}{\Omega}\right) \right] + \kappa_{HBM}^2 \left[ C_{2,2} \exp\left(\frac{-2 i \pi z}{\Omega}\right) + C_{2,0} + C_{2,-2} \exp\left(-\frac{-2 i \pi z}{\Omega}\right) \right],
\]

with the \( 4 \times 4 \) matrices \( A', C_{1,\pm 1}, C_{2,0}, \) and \( C_{2,\pm 2} \) being independent of \( z \) and \( \kappa_{HBM} \) but not of the half-period \( \Omega \) and the handedness parameter \( h \). Explicit representations of \( M'(z, \omega) \) are straightforwardly derived but cumbersome; the reader is referred elsewhere for further details [33].

In the case of axial propagation (i.e., \( \kappa_{HBM} = 0 \)), the solution to Eq. (51) is conveniently expressed in closed form as [102]

\[
F_0'(z) = \exp(i A' z) F_0'(0).
\]

The nonaxial propagation case (i.e., \( \kappa_{HBM} \neq 0 \)) is considerably more complicated to handle. However, Eq. (53) can be exploited to derive a solution to Eq. (51) in terms of a power series in \( z \) [106]. As an alternative, a piecewise uniform approximation may also be implemented [107,108].

The propensity of HBMs to exhibit characteristics related to negative refraction has been explored for the particular cases of chiral ferroelectric materials (which are characterized by the constitutive relations in Eq. (44) with \( \epsilon_{HBM} \) and \( \mu_{HBM} \) having uniaxial forms, and the magnetoelectric dyadics \( \xi_{HBM} \) and \( \zeta_{HBM} \) being null valued) [27] and chiral ferroelectric materials (which are characterized by the constitutive Eqs. (44) with \( \epsilon_{HBM} \) and \( \mu_{HBM} \) having biaxial forms, and the magnetoelectric dyadics \( \xi_{HBM} \) and \( \zeta_{HBM} \) being null valued) [28]. In both instances, it was observed that the structural handedness of the materials is effectively reversed when the real parts of the permittivity and permeability parameters are changed from positive to negative. That is, a structurally right/left-handed HBM with negative real permittivity and permeability parameters exhibits the circular Bragg phenomenon as though it were a structurally left/right-handed HBM with positive real permittivity and permeability parameters. Furthermore, when the real parts of the permittivity and permeability parameters are changed from positive to negative, the reflection and transmission coefficients undergo a phase reversal that can result
in negative Goos–Hänchen shifts [28]. Such negative Goos–Hänchen shifts are a characteristic of materials that support NPV [110–113].

3.3 Ambichirality

Imagine a uniaxial crystalline sheet whose distinguished axis is oriented normal to the sheet’s thickness direction. Now consider stack of such sheets with the angle between the distinguished axes of each pair of neighbouring sheets being $\pi/q$, $q = 2, 3, \ldots$. For $q > 2$ this stack represents an ambichiral material, as originally conceived by Reusch [32] and later analyzed by Joly and Billard [114]. As is true for HBMs (which may be viewed as the limiting case $q \to \infty$), ambichiral materials can exhibit different Bragg resonances for different circular polarization states. However, if the dielectric and magnetic dyadics of the underlying constituent materials are indefinite, the corresponding ambichiral material loses its ability to discriminate between different circular polarization states, provided that the number of constituent sheets is sufficiently large. This property—which arises because two of the four planewave components in each sheet are of the NPV type and two are of the positive-phase-velocity type—enables such an ambichiral material to function as a polarization-universal rejection filter [116].

The ambichiral architecture essentially underpins a recent report by Plum et al. [117] of a negatively refracting metamaterial, based on a stack of sheets each containing metallic rosettes with every sheet rotated about the normal axis with respect to the previous sheet in the stack by an angle less than 90 deg. An illustration is provided in Fig. 12. A similarly stacked chiral metamaterial that supports negative refraction, with a cross-wire microstructure, has been described by Zhou et al. [118].

4 Closing Remarks

The interaction of light with chiral metamaterials presents promising opportunities. In this review we have highlighted the propensity of these metamaterials to support negative refraction and closely related phenomena. However, these opportunities come at a price: there are also formidable challenges, both experimental and theoretical, associated with chiral metamaterials. As we highlight in Sec. 2.5, the characterization of the complex behavior exhibited by these metamaterials requires careful treatment. In particular, optical properties cannot be characterized

---

1The $q = 2$ case—which corresponds to an *equichiral* material—is of little technological interest as such materials exhibit the same Bragg resonances for both circular polarization states [115].
Fig. 13  Two of the eight sculptures from the permanent installation The Matter of Time by Richard Serra at the Guggenheim Museum Bilbao. The sculpture on the left may remind the reader of a Swiss roll, the one on the right of a double split-ring resonator, both structures commonplace in the literature on negatively refracting metamaterials. Were the metal sheets in both sculptures strictly vertical, both would be achiral.

by a simple scalar refractive index that refers only to one mode of propagation, along one direction only. Instead, multiple wavevectors, which may be directionally dependent, need to be considered. The comprehensive characterization of optical properties may involve significant distinctions still being made between counterposition, NPV, and negative refraction.

A perusal of ongoing experimental research on optical (frequency \( \lesssim 500 \text{ THz} \)) metamaterials shows that standard micro- and nano-fabrication techniques are being used to make them [12,15,100,119–122]. Metamaterials for operation at frequencies exceeding 500 THz would have to be engineered on the nanoscale [15,119]. Remarkable optical effects can be expected from nanoengineered metamaterials, as nanotechnology for optics is a play of phase, length, and time [123]. As quantum-confinement effects will also emerge at higher frequencies [124], a strict scaling down of classical electromagnetics [125] may not suffice for designing both metamaterials and metamaterial-based devices. The associated difficulties are likely to be accentuated for asymmetric morphology at the nanoscale and, thus, for chiral metamaterials. To compensate, we must note that nanofabrication methods [126–128] are suited well to produce assemblies of different kinds of electrically small cells for multifunctional performance at the macroscopic scale.

While metamaterials (chiral or otherwise) have much to offer, after the past nine years or more of intensive research there still remains a wide gulf between the research frontier and practical applications [129]. One major issue to be tackled is the dissipation of electromagnetic energy in a material of reasonable thickness. Either pre-amplification or the incorporation of gain materials appears necessary, though we must note that the energy budget may then turn out to be economically impractical. Another major issue is the rapid variation of constitutive parameters with frequency in the frequency regimes of interest. This large dispersion could significantly distort pulse-modulated waves. Ingenuity and perseverance—perhaps, along with serendipity—are needed to find economically viable metamaterials that refract negatively.

Acknowledgments

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We are happy to acknowledge parallels between ideas in the technoscientific and artistic worlds by drawing the reader’s attention to Fig. 13 comprising photographs of two sculptures of Richard Serra installed at the Guggenheim Museum, Bilbao, Spain.
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[85] A. Lakhtakia and W. S. Weiglhofer, “Electromagnetic waves in a material with simultaneous mirror-conjugated and racemic chirality characteristics,” *Electromagnetics* 20, 481–488 (2000). (The first negative sign on the right side of Eq. (26) of this paper should be replaced by a positive sign).


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